

5A, 800V N-CHANNEL MOSFET

GENERAL DESCRIPTION

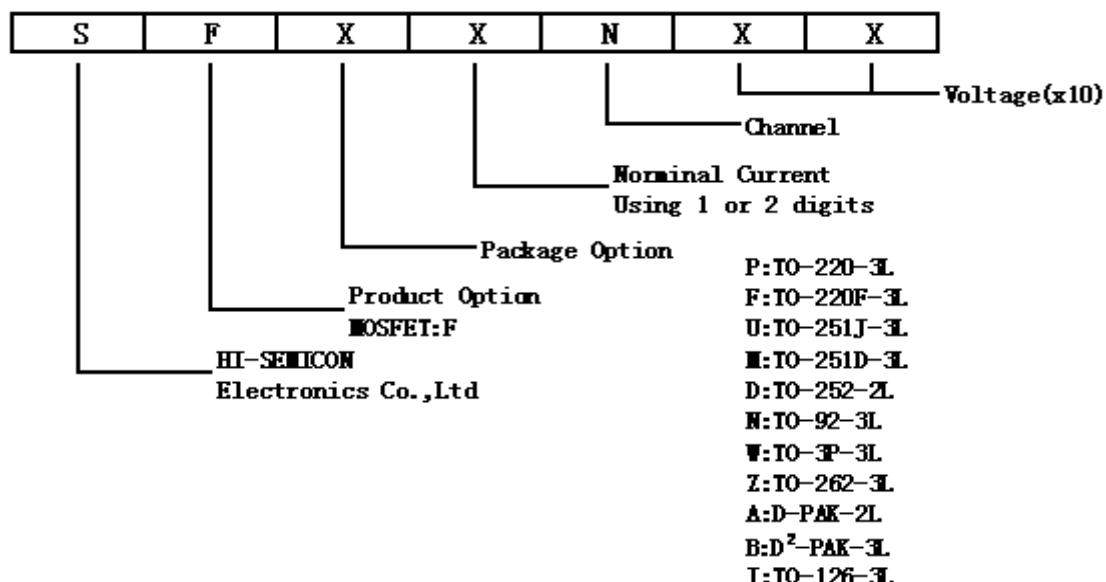
This power mosfet is an N-channel enhancement mode power MOS field effect transistor which is produced using Hi-semicon proprietary F-Cell™ structure VDMOS technology. The improved planar stripe cell and the improved guarding ring terminal have been especially tailored to minimize on-state resistance, provide superior switching performance, and withstand high energy pulse in the avalanche and commutation mode.

These devices are widely used in AC-DC power suppliers, DC-DC converters and H-bridge PWM motor drivers.

FEATURES

- ◆ 5A,800V, $R_{DS(on)}(typ) = 2.0\Omega$ @ $V_{GS} = 10V$
- ◆ Low gate charge
- ◆ Low Crss
- ◆ Fast switching
- ◆ Improved dv/dt capability

NOMENCLATURE



ORDERING INFORMATION

Part No.	Package	Marking	Material	Packing
SFF5N80	TO-220F-3L	SFF5N80	Pb free	Tube
SFP5N80	TO-220-3L	SFP5N80	Pb free	Tube

ABSOLUTE MAXIMUM RATINGS ($T_c=25^\circ\text{C}$ unless otherwise noted)

Characteristics	Symbol	Ratings		Unit
		SFF5N80	SFP5N80	
Drain-Source Voltage	V_{DS}	800		V
Gate-Source Voltage	V_{GS}	± 30		V
Drain Current	I_D	5.0		A
		3.2		
Drain Current Pulsed	I_{DM}	20		A
Power Dissipation($T_c=25^\circ\text{C}$) -Derate above 25°C	P_D	48	146	W
		0.38	1.17	W/ $^\circ\text{C}$
Single Pulsed Avalanche Energy (Note 1)	E_{AS}	323		mJ
Operation Junction Temperature Range	T_J	$-55 \sim +150$		$^\circ\text{C}$
Storage Temperature Range	T_{stg}	$-55 \sim +150$		$^\circ\text{C}$

THERMAL CHARACTERISTICS

Characteristics	Symbol	Ratings		Unit
		SFF5N80	SFP5N80	
Thermal Resistance, Junction-to-Case	$R_{\theta JC}$	2.60	0.86	$^\circ\text{C/W}$
Thermal Resistance, Junction-to-Ambient	$R_{\theta JA}$	120	62.5	$^\circ\text{C/W}$

ELECTRICAL CHARACTERISTICS ($T_c=25^\circ\text{C}$ unless otherwise noted)

Characteristics	Symbol	Test conditions	Min.	Typ.	Max.	Unit
Drain -Source Breakdown Voltage	B_{VDSS}	$V_{GS}=0\text{V}, I_D=250\mu\text{A}$	800	--	--	V
Drain-Source Leakage Current	I_{DSS}	$V_{DS}=800\text{V}, V_{GS}=0\text{V}$	--	--	1.0	μA
Gate-Source Leakage Current	I_{GSS}	$V_{GS}=\pm 30\text{V}, V_{DS}=0\text{V}$	--	--	± 100	nA
Gate Threshold Voltage	$V_{GS(\text{th})}$	$V_{GS}=V_{DS}, I_D=250\mu\text{A}$	2.0	--	4.0	V
Static Drain- Source On State Resistance	$R_{DS(\text{on})}$	$V_{GS}=10\text{V}, I_D=2.5\text{A}$	--	2.0	2.7	Ω
Input Capacitance	C_{iss}	$V_{DS}=25\text{V}, V_{GS}=0\text{V}, f=1.0\text{MHz}$	--	677.1	--	pF
Output Capacitance	C_{oss}		--	71.0	--	
Reverse Transfer Capacitance	C_{rss}		--	4.0	--	
Turn-on Delay Time	$t_{d(\text{on})}$	$V_{DD}=400\text{V}, I_D=5.0\text{A}, R_G=25\Omega$ (Note2, 3)	--	11.9	--	ns
Turn-on Rise Time	t_r		--	23.1	--	
Turn-off Delay Time	$t_{d(\text{off})}$		--	25.3	--	
Turn-off Fall Time	t_f		--	23.1	--	
Total Gate Charge	Q_g	$V_{DS}=640\text{V}, I_D=5.0\text{A}, V_{GS}=10\text{V}$ (Note2, 3)	--	15.16	--	nC
Gate-Source Charge	Q_{gs}		--	4.27	--	
Gate-Drain Charge	Q_{gd}		--	6.78	--	

SOURCE-DRAIN DIODE RATINGS AND CHARACTERISTICS

Characteristics	Symbol	Test conditions	Min.	Typ.	Max.	Unit
Continuous Source Current	I _S	Integral Junction Diode in the P-N MOSFET	--	--	5.0	A
Pulsed Source Current	I _{SM}		--	--	20	
Diode Forward Voltage	V _{SD}	I _S =5.0A, V _{GS} =0V	--	--	1.4	V
Reverse Recovery Time	T _{rr}	I _S =5.0A, V _{GS} =0V, dI/dt=100A/μS (Note2)	--	548.7	--	ns
Reverse Recovery Charge	Q _{rr}		--	2.95	--	μC

Notes:

1. L=30mH, I_{AS}=4.5A, V_{DD}=60V, R_G=25Ω, starting T_J=25°C;
2. Pulse Test: Pulse width ≤300μs, Duty cycle≤2%;
3. Essentially independent of operating temperature.

TYPICAL CHARACTERISTICS

Figure 1. On-Region Characteristics

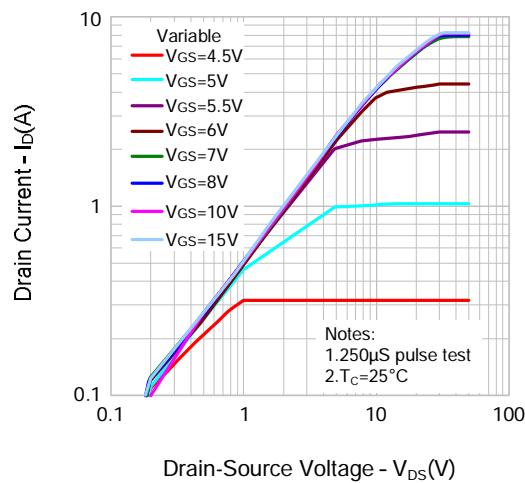


Figure 2. Transfer Characteristics

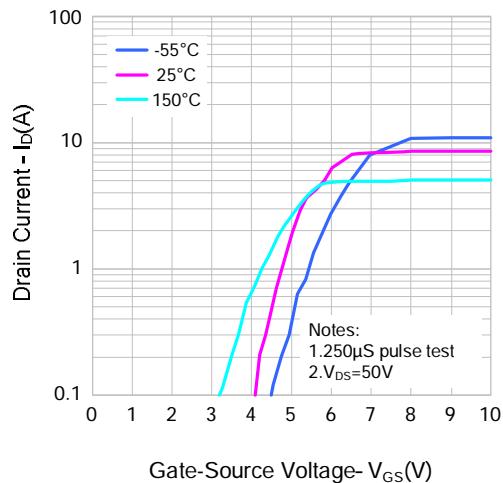


Figure 3. On-Resistance Variation vs. Drain Current and Gate Voltage

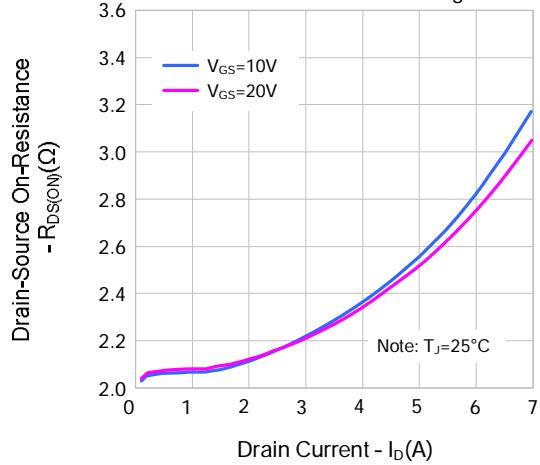


Figure 4. Body Diode Forward Voltage Variation vs. Source Current and Temperature

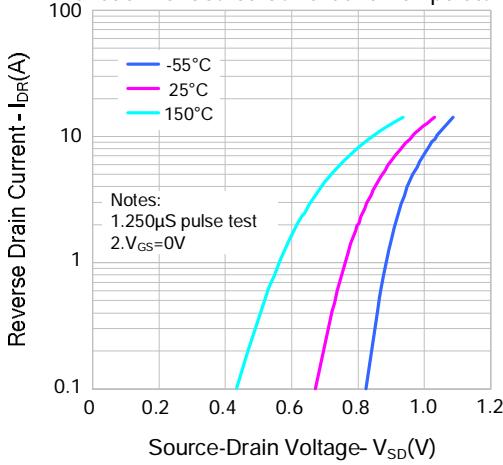


Figure 5. Capacitance Characteristics

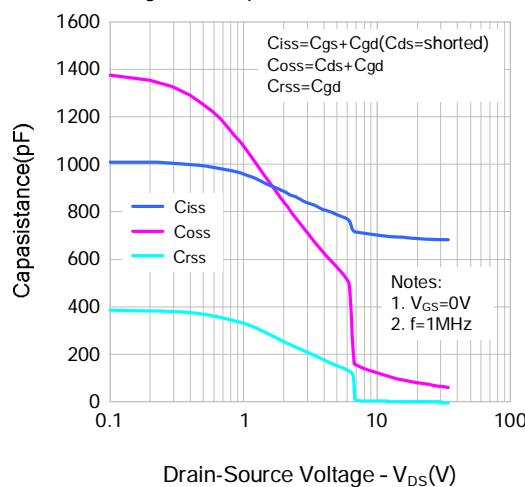
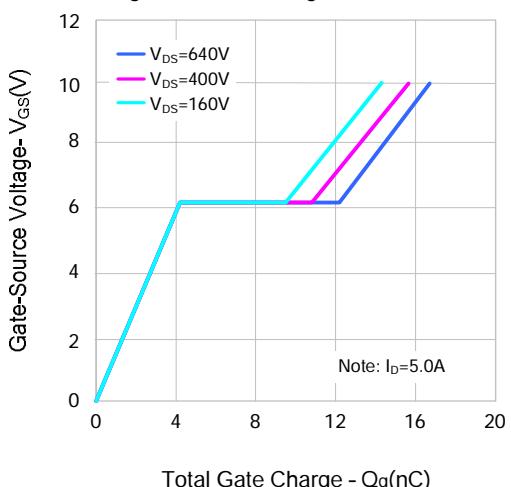


Figure 6. Gate Charge Characteristics



TYPICAL CHARACTERISTICS (continued)

Figure 7. Breakdown Voltage Variation vs. Temperature

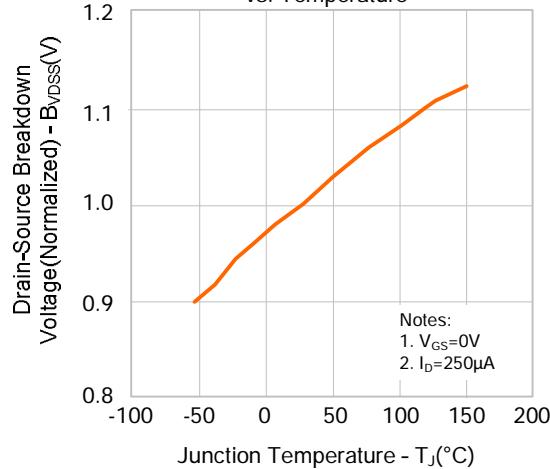


Figure 8. On-resistance Variation vs. Temperature

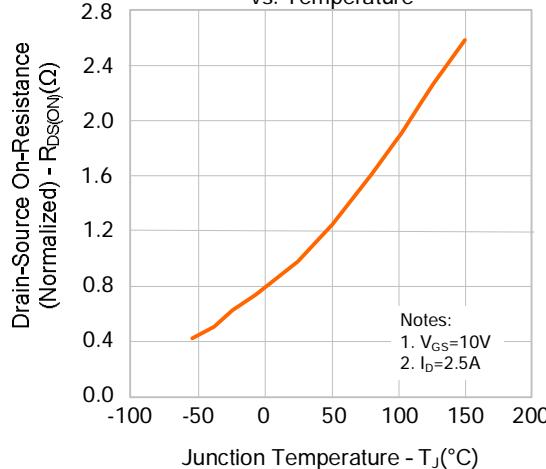


Figure 9-1. Max. Safe Operating Area(SF5N80)

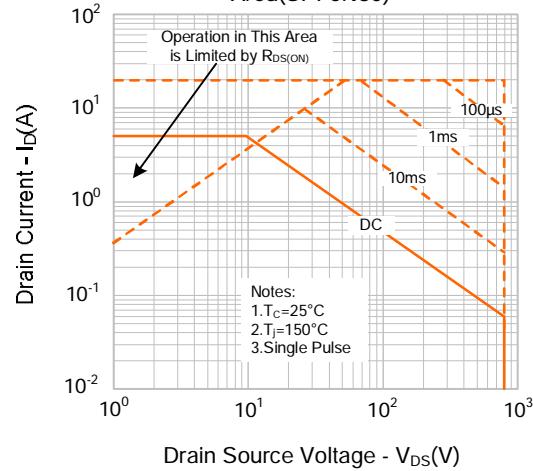


Figure 9-2. Max. Safe Operating Area(SFP5N80)

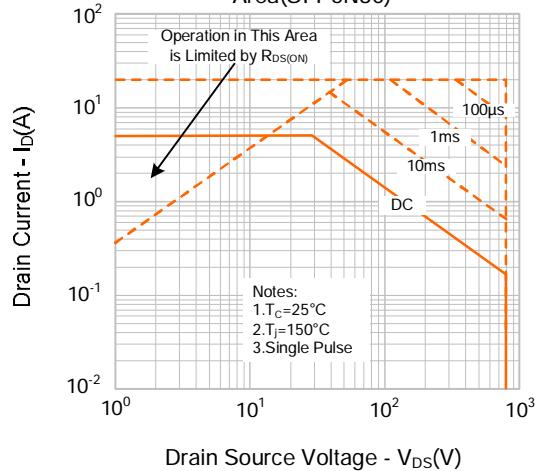
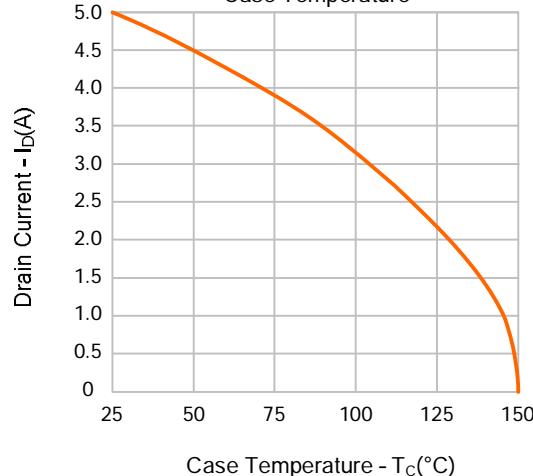
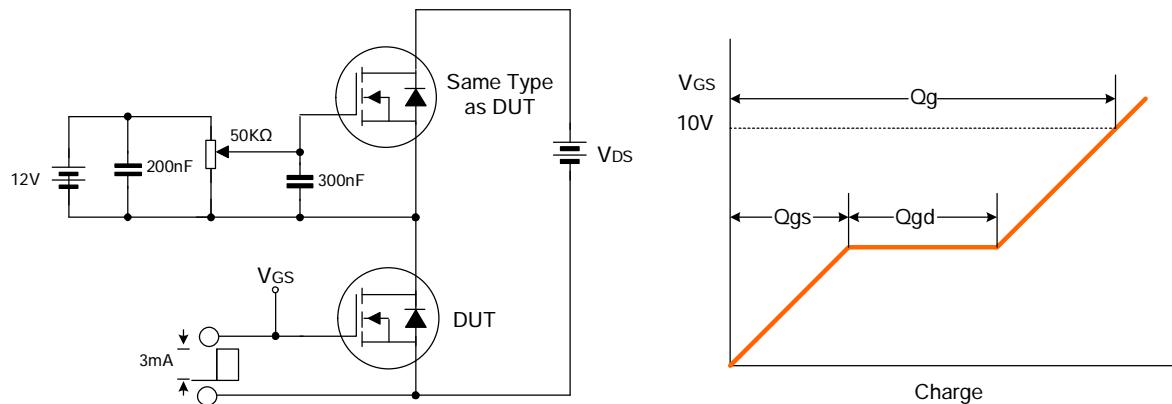


Figure 10. Maximum Drain Current vs. Case Temperature

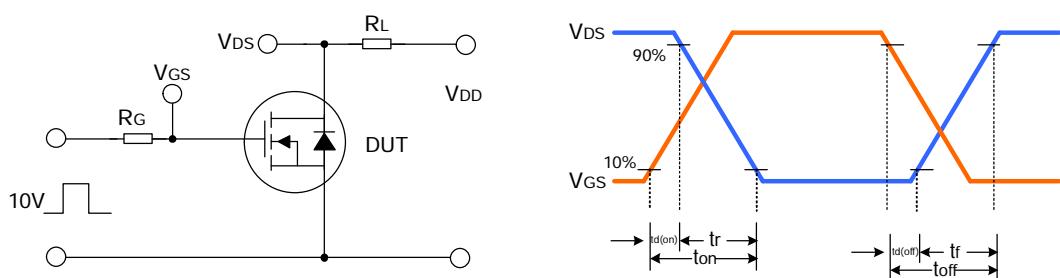


TYPICAL TEST CIRCUIT

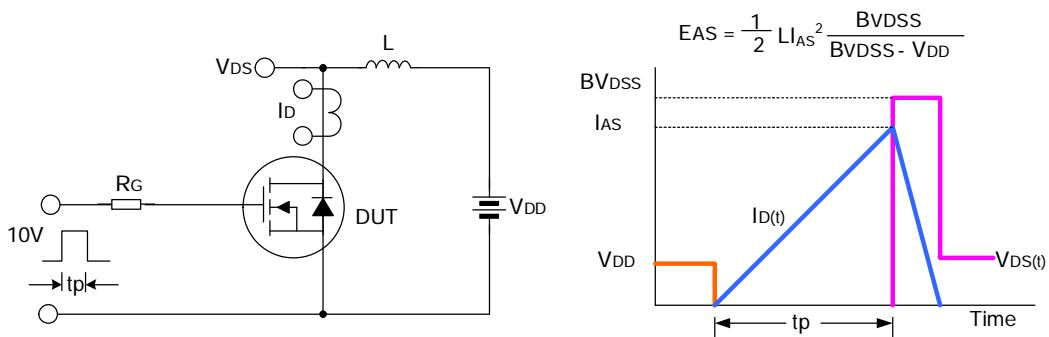
Gate Charge Test Circuit & Waveform



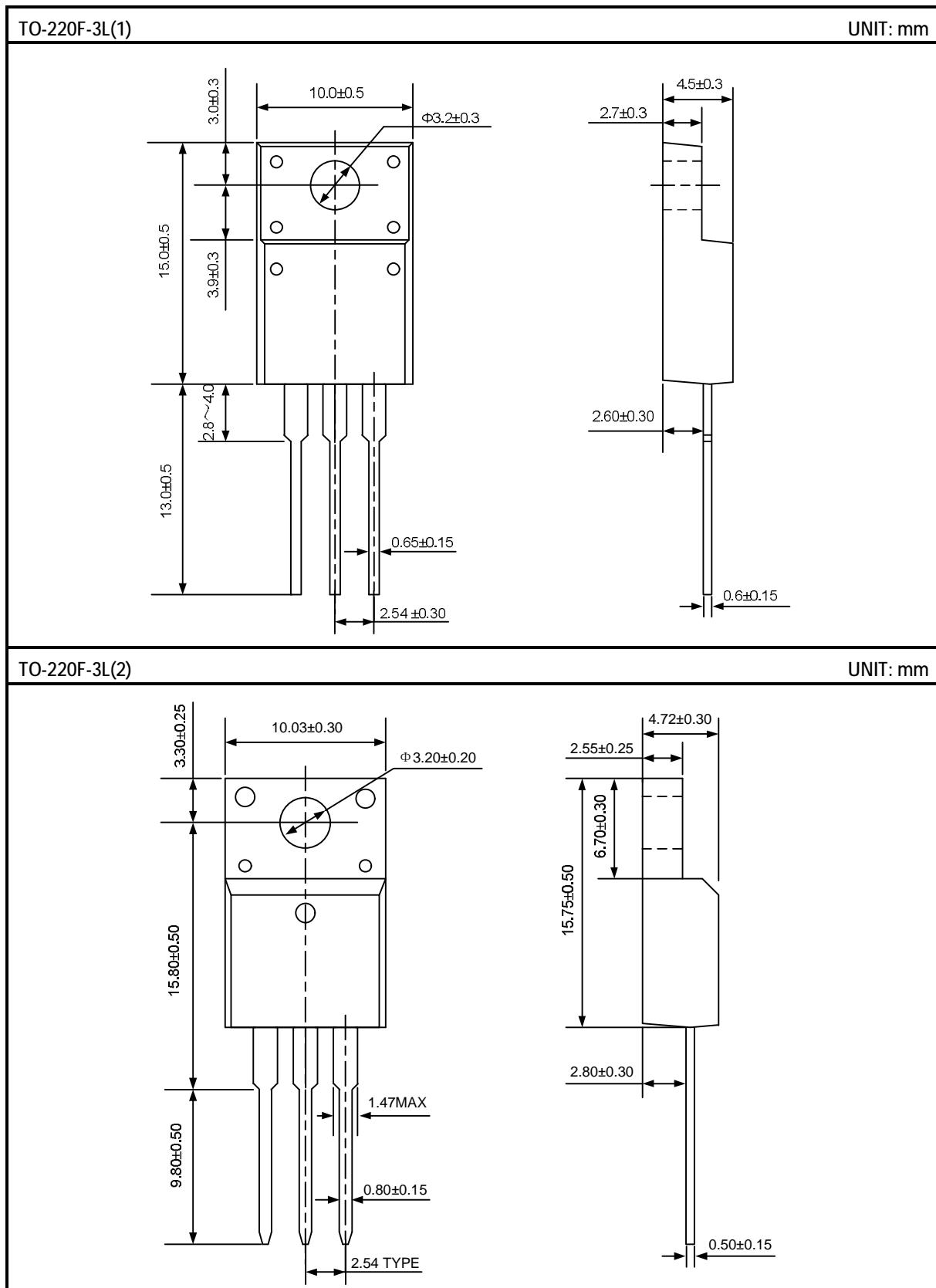
Switching Test Circuit & Waveform



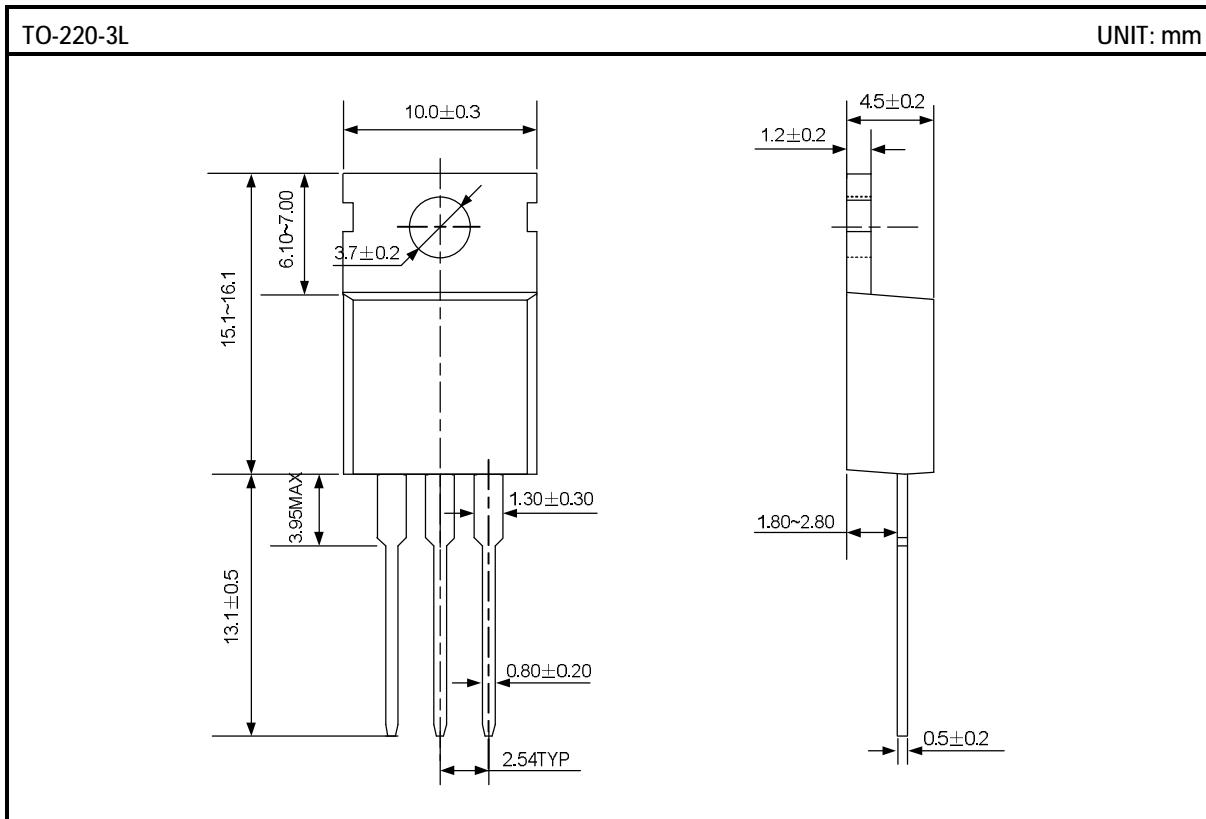
EAS Test Circuit & Waveform



PACKAGE OUTLINE



PACKAGE OUTLINE (continued)



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- Hi-semicon will supply the best possible product for customers!